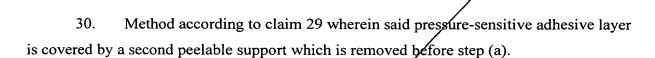
support and a UV-sensitive layer, wherein the adhesive layer is lammated to the UV-sensitive layer.

- (b) image-wise exposing the image recording layer to form a mask;
- (c) flood exposing the UV-sensitive material through the mask;
- (d) developing the UV-sensitive material; wherein the peelable support is removed either before step (b), (c) or (d) and wherein steps (a) to (d) are performed within a period of less than 2 months.
- 21. Method according to claim 20 wherein the UV-sensitive material further comprises an additional layer on top of the UV-sensitive layer and wherein the adhesive is laminated on top of the additional layer.
- 22. Method according to claim 20 wherein the image recording layer is a laser ablatable layer comprising a heat combustible polymeric binder and a light absorbing compound.
- 23. Method according to claim 20 wherein the image recording layer is a thin metallic layer.
- 24. Method according to claim 20 wherein the image recording layer is an ink jet receiving layer.
- 25. Method according to claim 20 wherein the image recording layer is a thermographic recording layer
- 26. Method according to claim 20 wherein the image recording layer is a photothermographic recording layer.
- 27. Method according to claim 20 wherein the first peelable support is a plastic film coated with a release agent on the side facing the image recording layer.
- 28. Method according to claim 20 wherein said adhesive layer is a thermosensitive adhesive layer.
 - 29. Method according to claim 20 wherein said adhesive layer is a pressure-



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- 31. Method according to claim 30 wherein the second peelable support is a plastic film coated with a release agent on the side facing the pressure-sensitive adhesive layer.
 - 32. Method according to claim 27/wherein the release agent is a silicone.
- 33. Method according to claim 20 wherein said UV-sensitive material is a photoresist material.
- 34. Method according to claim 20 wherein said UV-sensitive material is a lithographic printing plate precursor.
- 35. Method according to claim 20 wherein said UV-sensitive material is a flexographic printing plate precursor.
- 36. Method according to claim 20 wherein the mask is removed by the developing step (d).
- 37. Method according to claim 20 wherein the mask is removed by an additional developing step between step (c) and step (d).
- 38. Method according to claim 20 wherein the mask is removed by peel-off before developing step (d)